S/N: TBA 8/27/2003 Docket No.: AIA-100-C

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: TO BE ASSIGNED Confirmation No.: TO BE ASSIGNED

Continuation of 09/979,712

Applicant: Satoshi Amano, et al. Art Unit: TO BE ASSIGNED

Filed: August 27, 2003 Examiner: TO BE ASSIGNED

Docket No: AIA-100-C Customer No: 28892

For: Agent Promoting the Formation of Skin Basement Membrane, Agents Promoting the Formation of Artificial Skin and Process

for Producing Artificial Skin

APPLICATION DATA SHEET

(1) APPLICANT INFORMATION

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(3) APPLICATION INFORMATION

Skin Basement Membrane Formation <u>Title</u>

Promoting Agent, Artificial Skin Formation Promoting Agent and Production

Method for Artificial Skin

Total # Draw Sheets

Suggested Figure for

Publication

AIA-100-C Atty Docket Number Utility Type of Application

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MARCH 27, 2001)

(4) REPRESENTATIVE INFORMATION

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(5) DOMESTIC PRIORITY INFORMATION

None

(6) FOREIGN PRIORITY INFORMATION

2000-87574 Application Number

Japan Country

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S/N: TBA 8/27/2003 Docket No.: AIA-100-C

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